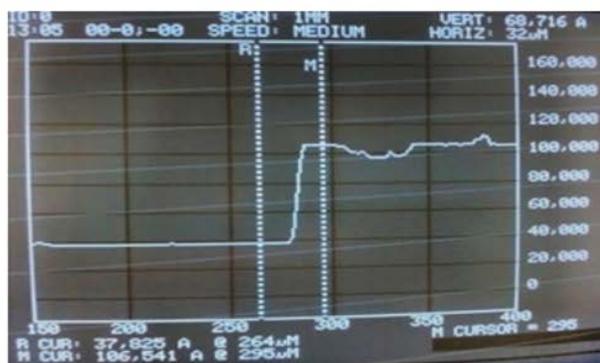


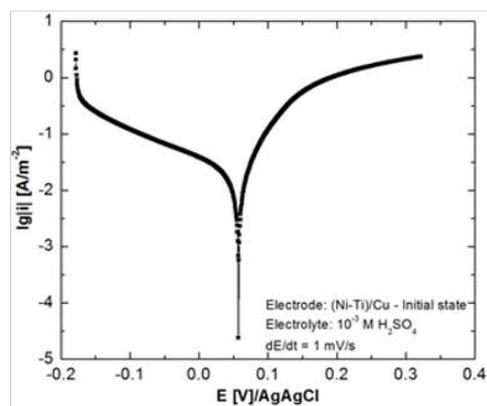
## Results 2019



Different substrates with Ni-Ti-based films deposited by magnetron sputtering (left) and the measurement of the film thickness (right)



Set-up in UPT ICR measurement



Linear polarization curves (Tafel plots) on (Ni-Ti)/Cu electrode in H<sub>2</sub>SO<sub>4</sub> 10<sup>-3</sup> M + 0.1 ppm F-1 at room temperature recorded at 1mV/s scan rate.